L Number	Hits	Search Text	DB	Time stamp
1	27	((313/582-587).CCLS.) and (lead adj oxide pbo) same (boron adj oxide "B.sub.2O.sub.3" "B.sub.2 O.sub.3") and powder same (coat$5 layer$5 jacket$5 film skin plating plated sublayer sub adj layer lamina$5) same (firing fired)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/13 10:44
2	27	((313/582-587).CCLS.) and (lead adj oxide pbo) same (boron adj oxide "B.sub.2O.sub.3" "B.sub.2 O.sub.3") and powder same (coat$5 layer$5 jacket$5 film skin plating plated sublayer sub adj layer lamina$5) same (firing fired)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/13 10:50
3	11	((313/582-587).CCLS.) and (lead adj oxide pbo) and powder same (coat$5 layer$5 jacket$5 film skin plating plated sublayer sub adj layer lamina$5) same (firing fired) same dielectric adj (coat$5 layer$5 jacket$5 film skin plating plated sublayer sub adj layer lamina$5)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/13 12:15
4	2	6160345.pn.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/13 11:32
5	2	6160345.pn. and dielectric adj layer	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/13 11:33
6	1	6160345.pn. and dielectric adj layer same powder	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/13 11:34
7	1	6160345.pn. and dielectric adj layer and powder	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/13 11:36
8	2	6160345.pn. and dielectric adj layer same (bake baking baked)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/13 11:36
9	0	6160345.pn. and dielectric adj layer same (bake baking baked) same powder	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/13 11:37
10	1	6160345.pn. and dielectric adj layer same (bake baking baked) and powder$5	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/13 11:37
11	2	20040027071.did.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/13 11:52
12	2	20040027071.did. and pigment	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/13 11:58
13	61	calcium adj oxide near2 pigment	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/13 12:00

14	0	((315/169.3).CCLS. (345/60).ccls.) and (lead adj oxide pbo) and powder same (coat$5 layer$5 jacket$5 film skin plating plated sublayer sub adj layer lamina$5) same (firing fired) same dielectric adj (coat$5 layer$5 jacket$5 film skin plating plated sublayer sub adj layer lamina$5)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/13 12:16
15	10	(((315/169.3).CCLS. (345/60).ccls.)) and (lead adj oxide pbo) same (boron adj oxide "B.sub.2O.sub.3" "B.sub.2 O.sub.3") and ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.2O.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.2O.sub.5" "Ta.sub.2 O.sub.5")) and (percent%6 "%")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/13 12:16
16	10	(((315/169.3).CCLS. (345/60).ccls.)) and (lead adj oxide pbo) same (boron adj oxide "B.sub.2O.sub.3" "B.sub.2 O.sub.3") and ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.2O.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.2O.sub.5" "Ta.sub.2 O.sub.5")) and (percent%6 "%")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/13 12:32
17	2	20010024582.did.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/13 12:32
18	2	6160345.pn.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/13 12:33
19	1	6160345.pn. and soften$6	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/13 12:33
-	10	("6617789" "6497962" "6419540" "6160345" "6376400" "6355586" "5948537" "5714840").pn. ("20020034917" "20020036466").did.	USPAT; US-PGPUB	2004/10/12 16:22
-	209	glass.ab,ti,clm. and (lead adj oxide PbO) and (boron adj oxide "B.sub.2O.sub.3" "B.sub.2 O.sub.3") and (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2") and (titanium adj oxide "TiO.sub.2" "Ti O.sub.2") and (zirconium adj oxide "ZrO.sub.2") and (lanthanum adj oxide "La.sub.2O.sub.3" "La.sub.2 O.sub.3") and (tantalum adj oxide "Ta.sub.2O.sub.5" "Ta.sub.2 O.sub.5")	USPAT; US-PGPUB	2004/10/12 13:38
-	212	glass.ab,ti,clm. and (lead adj oxide PbO) and (boron adj oxide "B.sub.2O.sub.3" "B.sub.2 O.sub.3") and (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2") and (titanium adj oxide "TiO.sub.2" "Ti O.sub.2") and (zirconium adj oxide "ZrO.sub.2") and (lanthanum adj oxide "La.sub.2O.sub.3" "La.sub.2 O.sub.3") and (tantalum adj oxide "Ta.sub.2O.sub.5" "Ta.sub.2 O.sub.5")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 13:38

-		147	glass.ab,ti,clm. and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2") and (titanium adj oxide "TiO.sub.2" "Ti O.sub.2") and (zirconium adj oxide "ZrO.sub.2") and (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") and (tantalum adj oxide "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 13:39
-		77	glass.ab,ti,clm. and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2") same (titanium adj oxide "TiO.sub.2" "Ti O.sub.2") same (zirconium adj oxide "ZrO.sub.2") same (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") same (tantalum adj oxide "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 13:39
-		72	glass.ab,ti,clm. and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2") same (titanium adj oxide "TiO.sub.2" "Ti O.sub.2") same (zirconium adj oxide "ZrO.sub.2") same (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") same (tantalum adj oxide "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5") and (percent "%")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 13:40
-		72	glass.ab,ti,clm. and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2") same (titanium adj oxide "TiO.sub.2" "Ti O.sub.2") same (zirconium adj oxide "ZrO.sub.2") same (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") same (tantalum adj (pentoxide oxide) "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5") and (percent "%")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 13:40
-		40	glass.ab,ti,clm. and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2") same (titanium adj oxide "TiO.sub.2" "Ti O.sub.2") same (zirconium adj oxide "ZrO.sub.2") same (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") same (tantalum adj (pentoxide oxide) "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5") same (percent "%")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 13:43
-		9	glass.ab,ti,clm. and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2") same (titanium adj oxide "TiO.sub.2" "Ti O.sub.2") same (zirconium adj oxide "ZrO.sub.2") same (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") same (tantalum adj (pentoxide oxide) "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5") same (percent "%") and softening adj point	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 13:44

-		6	glass.ab,ti,clm. and (lead adj oxide PbO) same (boron adj oxide "B.sub.2O.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2") same (titanium adj oxide "TiO.sub.2" "Ti O.sub.2") same (zirconium adj oxide "ZrO.sub.2") same (lanthanum adj oxide "La.sub.2O.sub.3" "La.sub.2 O.sub.3") same (tantalum adj (pentoxide oxide) "Ta.sub.2O.sub.5" "Ta.sub.2 O.sub.5") same (percent "%") and plasma	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 14:50
-		1	"20040180773"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 13:57
-		1	20040180773.did.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 13:57
-		0	(("6617789" "6497962" "6419540" "6160345" "6376400" "6355586" "5948537" "5714840").pn. ("20020034917" "20020036466").did.) and (lead adj oxide PbO) and (boron adj oxide "B.sub.2O.sub.3" "B.sub.2 O.sub.3") and (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2") and (titanium adj oxide "TiO.sub.2" "Ti O.sub.2") and (zirconium adj oxide "ZrO.sub.2") and (lanthanum adj oxide "La.sub.2O.sub.3" "La.sub.2 O.sub.3") and (tantalum adj (pentoxide oxide) "Ta.sub.2O.sub.5" "Ta.sub.2 O.sub.5") and (percent "%")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 14:17
-		0	(("6617789" "6497962" "6419540" "6160345" "6376400" "6355586" "5948537" "5714840").pn. ("20020034917" "20020036466").did.) and (lead adj oxide PbO) and (boron adj oxide "B.sub.2O.sub.3" "B.sub.2 O.sub.3") and (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2") and (titanium adj oxide "TiO.sub.2" "Ti O.sub.2") and (zirconium adj oxide "ZrO.sub.2") and (lanthanum adj oxide "La.sub.2O.sub.3" "La.sub.2 O.sub.3") and (tantalum adj (pentoxide oxide) "Ta.sub.2O.sub.5" "Ta.sub.2 O.sub.5")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 14:22
-		228	(fujimine near2 satoshi manabe near2 tsuneo).in.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 14:18
-		28	((fujimine near2 satoshi manabe near2 tsuneo).in.) and glass near2 powder and (lead adj oxide pbo)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 14:40
-		1	(((fujimine near2 satoshi manabe near2 tsuneo).in.) and glass near2 powder and (lead adj oxide pbo)) and (lead adj oxide PbO) and (boron adj (trioxide oxide) "B.sub.2O.sub.3" "B.sub.2 O.sub.3") and (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2") and (titanium adj oxide "TiO.sub.2" "Ti O.sub.2") and (zirconium adj oxide "ZrO.sub.2") and (lanthanum adj oxide "La.sub.2O.sub.3" "La.sub.2 O.sub.3") and (tantalum adj (pentoxide oxide) "Ta.sub.2O.sub.5" "Ta.sub.2 O.sub.5")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 14:38

-		1	20040027071.did. and "TiO.sub.2"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 14:38
-		8	(((fujimine near2 satoshi manabe near2 tsuneo).in.) and glass near2 powder and (lead adj oxide pbo)) and "+"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 14:41
-		3	(((fujimine near2 satoshi manabe near2 tsuneo).in.) and glass near2 powder and (lead adj oxide pbo)) and "+".clm.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 14:41
-		57	glass.ab,ti,clm. and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2") same ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5")) same (percent "%") and plasma	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 14:51
-		57	glass.ab,ti,clm. and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2") same ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5")) same (percent "%") and plasma	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 14:52
-		8	glass.ab,ti,clm. and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2") same ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5")) same (percent "%") and plasma and (copper adj oxide Cuo) and (saphire sapphire aluminum adj oxide "al.sub.20.sub.3" "al.sub.2 O.sub.3") and (barium adj oxide bao)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 15:06
-		2	6555594.URPN.	USPAT	2004/10/12 15:05
-		9	(silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2" silica).ab,ti,clm. and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2" silica) same ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5")) same (percent "%") and plasma and (copper adj oxide Cuo) and (saphire sapphire aluminum adj oxide "al.sub.20.sub.3" "al.sub.2 O.sub.3") and (barium adj oxide bao)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 15:07

-	52	(silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2" silica).ab,ti,clm. and (lead adj oxide PbO) same (boron adj oxide "B.sub.2O.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2" silica) same ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.2O.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.2O.sub.5" "Ta.sub.2 O.sub.5")) same (percent "%") and plasma and ((copper adj oxide Cuo) ((saphire sapphire aluminum adj oxide "al.sub.2O.sub.3" "al.sub.2 O.sub.3") and (barium adj oxide bao)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 15:10
-	15	(silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2" silica).ab,ti,clm. and (lead adj oxide PbO) same (boron adj oxide "B.sub.2O.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2" silica) same ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.2O.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.2O.sub.5" "Ta.sub.2 O.sub.5")) same (percent "%") same ((copper adj oxide Cuo) ((saphire sapphire aluminum adj oxide "al.sub.2O.sub.3" "al.sub.2 O.sub.3") and (barium adj oxide bao))) and plasma	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 15:36
-	199	(silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2" silica).ab,ti,clm. and (lead adj oxide PbO) same (boron adj oxide "B.sub.2O.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2" silica) same ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.2O.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.2O.sub.5" "Ta.sub.2 O.sub.5")) same (percent "%") same ((copper adj oxide Cuo) ((saphire sapphire aluminum adj oxide "al.sub.2O.sub.3" "al.sub.2 O.sub.3") and (barium adj oxide bao)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 15:37
-	4	(silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2" silica).ab,ti,clm. and (lead adj oxide PbO) same (boron adj oxide "B.sub.2O.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2" silica) same ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.2O.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.2O.sub.5" "Ta.sub.2 O.sub.5")) same (percent "%") same ((copper adj oxide Cuo) ((saphire sapphire aluminum adj oxide "al.sub.2O.sub.3" "al.sub.2 O.sub.3") and (barium adj oxide bao))) and pdp	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 15:40

-	8	(plasma adj display adj panel pdp).ab,ti,clm. and (lead adj oxide PbO) same (boron adj oxide "B.sub.2O.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2" silica) same ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.2O.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.2O.sub.5" "Ta.sub.2 O.sub.5")) same (percent "%") same ((copper adj oxide Cuo) ((saphire sapphire aluminum adj oxide "al.sub.2O.sub.3" "al.sub.2 O.sub.3") and (barium adj oxide bao))) and softening adj point	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 15:53
-	2	20020096666.did.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 16:38
-	1	6238847.pn. and barium	USPAT; US-PGPUB	2004/10/12 16:23
-	1	6238847.pn. and (barium BaO)	USPAT; US-PGPUB	2004/10/12 16:27
-	0	6238847.pn. and softening	USPAT; US-PGPUB	2004/10/12 16:27
-	1	6238847.pn.	USPAT; US-PGPUB	2004/10/12 16:36
-	1	20020096666.did. and electrode	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 16:42
-	487	(313/586).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 16:42
-	113	((313/586).CCLS.) and (lead adj oxide pbo)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 16:42
-	53	((313/586).CCLS.) and (lead adj oxide pbo) same (boron adj oxide "B.sub.2O.sub.3" "B.sub.2 O.sub.3")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 16:43
-	18	((313/586).CCLS.) and (lead adj oxide pbo) same (boron adj oxide "B.sub.2O.sub.3" "B.sub.2 O.sub.3") and ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.2O.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.2O.sub.5" "Ta.sub.2 O.sub.5"))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 16:45
-	5	((313/586).CCLS.) and (lead adj oxide pbo) same (boron adj oxide "B.sub.2O.sub.3" "B.sub.2 O.sub.3") same ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.2O.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.2O.sub.5" "Ta.sub.2 O.sub.5"))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 16:44

-	15	((313/586).CCLS.) and (lead adj oxide pbo) same (boron adj oxide "B.sub.2O.sub.3" "B.sub.2 O.sub.3") and ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.2O.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.2O.sub.5" "Ta.sub.2 O.sub.5")) and (percent%6 "%")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 22:30
-	2	20010024582.did.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 16:59
-	1	20010024582.did. and softening adj point	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 16:59
-	1	20010024582.did.	USPAT; US-PGPUB	2004/10/12 22:03
-	1	20010024582.did. and BaO	USPAT; US-PGPUB	2004/10/12 22:05
-	1	20010024582.did. and BaO same PbO	USPAT; US-PGPUB	2004/10/12 22:16
-	1	20010024582.did. and softening adj point	USPAT; US-PGPUB	2004/10/12 22:16
-	2	20040027071.did.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/13 11:52
-	38	((313/582-587).CCLS.) and (lead adj oxide pbo) same (boron adj oxide "B.sub.2O.sub.3" "B.sub.2 O.sub.3") and ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.2O.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.2O.sub.5" "Ta.sub.2 O.sub.5")) and (percent%6 "%")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/13 12:16
-	1	6160345.pn.	USPAT; US-PGPUB	2004/10/12 22:46